

On the Mathematical Analysis and Optimization of Chemical Vapor Infiltration [†]

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ABSTRACT

In this paper we present an analysis of the partial differential equations that describe the Chemical Vapor Infiltration (CVI) processes. The mathematical model requires at least two partial differential equations, one describing the gas phase and one corresponding to the solid phase.

A key difficulty in the process is the long processing times that are typically required. We address here the issue of optimization and show that we can choose appropriate pressure and temperature to minimize these processing times.

I Introduction

A variety of materials are produced by infiltration processes. In these techniques a fluid phase (i.e., a gas or a liquid) is transported into a porous structure, where it then reacts to form a solid product. These methods are particularly important for producing composite materials, where the initial porous preform is composed of the reinforcement phase (i.e., fibers, whiskers, or particles) and infiltration produces the matrix [1], [2]. A detailed assessment of the relevant reaction and mass transport rates during infiltration requires mathematical modeling, using a minimum of two coupled partial differential equations which describe changes in the reactant concentration and the solid structure as a function of both position and time. This type of modeling can also be extended to analyze the optimization and control of infiltration processes.

The research presented here specifically considers optimization for a set of two PDE's which describe isothermal, isobaric chemical vapor infiltration (CVI). In this process a vapor-phase precursor is transported into the porous preform, and a combination of gas and surface reactions leads to the deposition of the solid matrix phase. During infiltration the formation of the solid product phase eventually closes off porosity at the external surface of the body, blocking the flow of reactants and effectively ending the process. This is a key feature of most infiltration processes. Isothermal, isobaric CVI often requires extremely long times, so it is generally important to minimize the total processing times.

This paper considers the problem of determining the optimal pressure and temperature which correspond to the minimum infiltration time. From a practical perspective, the nature of the porous preform is often predetermined by the intended application (e.g., the physical dimensions and the fiber size are invariants). Thus, the process can only be controlled with process variables: temperature, pressure, and gas composition. Note that the pressure and temperature determine several different physical quantities in the model, such that the a general understanding of the optimum conditions is not immediately obvious from the basic formulation.

We adopted two strategies to solve the optimization problem. In the first we get an asymptotic approximation, valid when α^2 (defined in section 2) is small. We then used the explicit form of the asymptotic solution to get a functional of the pressure and temperature that estimates the optimal conditions for the process. In the second approach we get the

functional numerically.

This paper is organized as follows: Section 2 presents the basic set of two partial differential equations used to model isothermal, isobaric CVI (including initial and boundary conditions). A definition for a successful process and a discussion on the optimization problem is given. In Section 3 an analysis of the optimization problem is given. The analysis performed is based on asymptotic expansions as well as computations. The results of the analysis are optimal working pressure and temperature. In Section 4 the effects of powder formation in the analysis are included in the analysis; here too the pressure and temperature to minimize the final time are provided. In Section 5 a discussion of the significant of these results is presented.

II Formulation

A mathematical description of infiltration requires one or more partial differential equations which describe the evolution of the matrix (i.e., the solid phase), and one additional partial differential equation for each chemical species in the fluid phase. For a simple pore structure, the continuity equation for species i is

$$\frac{\partial(\varepsilon C_i)}{\partial t} + \nabla \cdot N_i = \sum_r^{n_r} \nu_{ir} R_r \quad (1)$$

where t is time, ε is the void fraction of the media, C_i and N_i are the concentration and the flux of species i respectively, n_r is the number of the gaseous species, ν_{ir} is the stoichiometric coefficients for the i th gaseous species in the r th reaction, and R_r represents the volumetric reaction rate of reaction r .

The basic partial differential equation(s) which describe reaction and mass-transport in porous media (i.e., the fluid phase) are well-established [3], [6]. For example, the Dusty-Gas model [7] is typically used to describe multicomponent diffusion and convection in a porous body.

$$\frac{N_i}{D_{K_i}} + \frac{RT}{P} \sum_{j \neq i} \frac{C_j N_i - C_i N_j}{\mathcal{D}_{M_{ij}}} = -\nabla C_i - \frac{C_i B_e}{\mu D_{K_i}} \nabla P \quad (2)$$

Where R is the gas constant, B_e is the permeability of the media, μ is the viscosity of the mixture P is the total pressure and T is the temperature. $\mathcal{D}_{M_{ij}}$ and D_{K_i} are the effective binary diffusivity for species i and j and the effective Knudsen diffusivity of species i , respectively.

In this paper we consider the binary (two gases mixture), diffusion-limited process, with one dilute reactant species in one spatial dimension. Under this conditions P is constant.

Describing the evolution of the matrix phase is equivalent to considering the change in the void fraction, ε (i.e., the volume fraction of gas inside of the porous solid). The evolution of ε is given by:

$$\frac{\partial \varepsilon}{\partial t} = -uS_v(\varepsilon) \quad (3)$$

Where u is the rate at which the solid product grows [volume/area/time] and $S_v(\varepsilon)$ is the gas/solid surface area per unit volume of the porous solid.

The preforms used for CVI typically have a complex porous structure. However, a cylindrical pore is often used to formulate simple models. This leads to the following expression for S_v :

$$S_v(\varepsilon) = \frac{2\sqrt{\varepsilon_0}\sqrt{\varepsilon}}{r_0} \quad (4)$$

where r_0 is the initial pore radius and ε_0 is the initial concentration of ε .

These assumptions leads to the following set of equations, (For more details on the derivation of the model see [4]):

$$\frac{\partial \eta(z, t)}{\partial t} = -\frac{\beta(t)}{2}c(z, t) \quad (5)$$

$$\frac{\partial}{\partial z} \left(f(\eta(z, t)) \frac{\partial c(z, t)}{\partial z} \right) = \alpha^2(t)\eta(z, t)c(z, t) \quad (6)$$

where

$$z = \frac{Z}{L} \quad (7)$$

$$c = \frac{C(z, t)}{C(0, t)} \quad (8)$$

$$f(\eta) = \frac{P\eta^3}{3(P\eta + A_D T)} \quad (9)$$

$$\eta = \sqrt{\varepsilon} \quad (10)$$

$$\alpha^2 = A_\alpha \frac{P e^{(-Q/T)}}{T^{3/2}} \quad (11)$$

$$\beta = A_\beta \frac{X_0 P e^{(-Q/T)}}{T} \quad (12)$$

Where L is the thickness of the preform, r_0 is the initial pore radius and X_0 denotes the fraction of the active gas in the inlet (at $z = 0$). $Q = E/R$, where E is the activation

Table I: Values of the constants.

A_α	$6.35 \cdot 10^{21} \text{ K}^{3/2} \text{ atm}^{-1}$
A_β	$3.64 \cdot 10^{18} \text{ K}^{3/2} \text{ atm}^{-1} \text{ sec}^{-1}$
$\eta_0 = \sqrt{\epsilon(t=0)}$	0.85
Q	55000 K [16]
A_D : 10 $_{\mu\text{m}}$ diam fibers	$1.54 \cdot 10^{-5} \text{ atm/K}$
80 $_{\mu\text{m}}$ diam fibers	$1.93 \cdot 10^{-6} \text{ atm/K}$
200 $_{\mu\text{m}}$ diam fibers	$7.7 \cdot 10^{-7} \text{ atm/K}$

energy. D_D is a lumped constant which is proportional to the ratio of the molecular and Knudsen diffusivities. Note that α^2 is dimensionless and that β has units of inverse time. The time derivative in Eq. (1) has been removed in Eq. (6), which is permissible because a pseudo steady state C profile is achieved in a short amount of time (i.e., compared to the time scale over which ϵ changes) [5]. Transforming ϵ to η simplifies equation (5). Note that η is proportional to S_v , so η can be viewed as a dimensionless surface area per volume. Values of the constants in Eqs.(9) - (12) are given in Table I, for the case of carbon CVI from methane, with a preform thickness of $2L = 3\text{mm}$.

The system (5), (6) is subject to the initial condition

$$\eta(z, 0) = \eta_0(z). \quad (13)$$

This paper treats only the case of a uniform initial condition, $\eta_0(z) = \eta_0$.

The boundary conditions most often used for CVI models are to fix the concentration at the outer surface of the preform, and to assume that diffusion occurs in from two opposite sides, such that there is no net flux in the middle of the preform (i.e., at $Z = L$, where L is the half-thickness of this 'virtual' preform). Thus the boundary conditions are:

$$c(0, t) = 1 \quad (14)$$

$$\left. \frac{\partial c}{\partial z} \right|_{z=1} = 0. \quad (15)$$

With this model it can be shown that:

1. The value of the void function in the inlet $z = 0$, is

$$\eta(0, t) = \eta_0 - \frac{\beta}{2}t \quad (16)$$

2. A classical solution exists and is unique for any time $t < t_c$, $t_c = \frac{2\eta_0}{\beta}$.

3. At the critical time $t_c = \frac{2\eta_0}{\beta}$ the void function η vanishes at $z = 0$, the inlet closes completely, and the process ends.

4. The void function η and the concentration function c are bounded from above and below. $0 < c(z, t) \leq 1$, $\eta(0, t) \leq \eta(z, t) \leq \eta_0$ for $t < t_c = \frac{2\eta_0}{\beta}$.

5. For any time $t < t_c$, the void function $\eta(z, t)$ is monotonically increasing function of the spatial variable z .

6. The concentration function $c(z, t)$ is monotonically decreasing function of the spatial variable z and

$$c(z, t) \leq \frac{\cosh \gamma (1 - z)}{\cosh \gamma}$$

where

$$\gamma = \sqrt{\frac{\eta_0}{f(\eta_0)}} \alpha \quad (17)$$

The existence and uniqueness were proved by Marion (private communication) the rest of the properties were proven in [12] in Lemma1 - Lemma 6.

A better lower bound on the concentration function $c(z, t)$ is needed for our optimization technique. This will be done in the following theorem:

Theorem 1 *Let $c(z, t)$ be the solution of (5) for $t < t_c$, then it is bounded from below by*

$$c(z, t) \geq \left[\frac{\cosh \gamma (1 - z)}{\cosh \gamma} \right]^{\frac{f(\eta_0)}{f(\eta(0, t))}} \quad (18)$$

Where γ is defined in (17)

Proof: We first note that the function

$$\frac{\cosh \gamma (1 - z)}{\cosh \gamma}$$

solves the equation

$$\frac{\partial}{\partial z} \left(f(\eta_0) \frac{\partial w}{\partial z} \right) - \alpha^2 \eta_0 w = 0 \quad (19)$$

With the boundary conditions $w(0) = 1$, $w'(1) = 0$. To complete the proof we need the following comparison Lemma:

Lemma 1 *Let, for $0 \leq z \leq 1$*

$$\frac{\partial}{\partial z} \left(a(z) \frac{\partial u}{\partial z} \right) - b(z) u = 0 ; \quad 0 < b \leq B \quad (20)$$

$$\frac{\partial}{\partial z} \left(A(z) \frac{\partial w}{\partial z} \right) - B(z) w = 0 ; \quad 0 < a \leq A \quad (21)$$

Where $a(z), b(z), A(z), B(z)$ are $C^1(0, 1)$ functions.

With boundary conditions:

$$\begin{aligned} u(0) &= w(0) > 0 , \\ \frac{\partial}{\partial z} u(1) &= \frac{\partial}{\partial z} w(1) = 0 . \end{aligned}$$

Then:

$$u, w > 0 , \quad \frac{\partial}{\partial z} u, \frac{\partial}{\partial z} w < 0$$

and

$$w(z) \leq w(0) e^{\int_0^z \frac{a}{A} \frac{u'}{u} d\zeta} \quad (22)$$

$$u(z) \geq u(0) e^{\int_0^z \frac{A}{a} \frac{w'}{w} d\zeta} \quad (23)$$

Proof We quote Lemma 3 in [12] that shows that $u, w > 0$ and $\frac{\partial}{\partial z} u, \frac{\partial}{\partial z} w < 0$.

By multiplying eq. (20) by w , eq. (21) by u and subtracting the two equations we get:

$$w (a u')' - b u w - u (A w')' - B u w = 0 ,$$

which is equivalent to

$$(w a u')' - (u A w')' = (b - B) u w + (a - A) u' w' \leq 0$$

Then by integrating between z and 1 and making use of the boundary conditions we get:

$$w a u' - u A w' \geq 0 .$$

we get eq. (22) and (23) by solving this inequality.

From the Lemma it is clear that

$$u(z) \geq w(z) \frac{\max A(z)}{\min a(z)}$$

We are ready now to prove the theorem. We consider equations (6) and (19) and identify

$$A(z) = f(\eta_0), B(z) = \alpha^2 \eta_0, \quad u = c(z, t).$$

and

$$a(z) = f(\eta), b(z) = \alpha^2 \eta, \quad w = \frac{\cosh(\gamma(1-z))}{\cosh \gamma}$$

Since $\eta \leq \eta_0$ and $f(\eta(0, t)) \leq f(\eta) \leq f(\eta_0)$ we can apply Lemma 1. to get (18)

□

The parameters α^2 and β depend on the three key process variables: T , P , and X_0 . Process optimization during CVI is achieved by setting these variables to optimal values. In isothermal, isobaric CVI the infiltration kinetics are controlled by diffusion and the deposition reaction. To achieve relatively uniform infiltration, diffusion must be fast relative to the deposition rate. This is typically accomplished by choosing processing conditions that result in a slow deposition rate, which usually leads to long infiltration times. Thus, the primary basis for process optimization is to obtain the desired amount of infiltration in the shortest possible time.

We will thus define what is a successful process:

Definition: A process is called successful if for some time $t_f < t_c$

$$\eta(z_1, t_f) \leq k_1 \eta_0 \tag{24}$$

$$\eta(0, t_f) = k_0 \eta_0 \tag{25}$$

$k_0 \ll 1, k_0 < k_1. 0 < z_1 \leq 1$

Equation (24) states that the final values of the void function η should be small in the interval between the inlet and the point z_1 (note that $\eta(z, t)$ is monotonically increasing function of the spatial coordinate z). In most problems of interest $z_1 = 1$. Conditions (24) and (25) state that the void function should be uniformly small.

We can determine explicitly the final time, t_f , in fact from (16), (25) :

$$t_f = (1 - k_0)\eta_0 \frac{2}{\beta}. \quad (26)$$

Note that the time for the process to end decreases as a function of β (itself a function of the temperature and pressure, given in (12)).

In the next theorem we will establish the fact that one can always find parameters α and β (actually, pressure and temperature that determine α and β) to achieve a successful process, in fact we can state :

Theorem 2 For all $0 < k_0 < k_1 < 1$ there exist temperature and pressure such that there is a successful process.

Proof

Property 1. stated that $\eta(0, t) = \eta_0 - \frac{\beta}{2}t$, so we can always satisfy (24) for the final time t_f defined in (26). The harder part is to show that we can always choose α to satisfy the uniformity condition (25).

By integrating eq. (5) we get

$$\eta(z_1, t_f) = \eta_0 - \int_0^{t_f} \frac{\beta}{2} c(z_1, t) dt \quad (27)$$

We change variables

$$\tau = E(t) = \eta_0 - \frac{\beta}{2}t, \quad (28)$$

and note that $E(0) = \eta_0, E(t_f) = k_0 \eta_0, d\tau = -\frac{\beta}{2} dt$. From Theorem Theorem.10 we get:

$$\begin{aligned} \eta(z_1, t_f) &= \eta_0 - \int_{k_0 \eta_0}^{\eta_0} c(z_1, \tau) d\tau \\ &\leq \eta_0 - \int_{k_0 \eta_0}^{\eta_0} \left[\frac{\cosh \gamma (1 - z_1)}{\cosh \gamma} \right]^{\frac{f(\eta_0)}{f(\eta(0, t))}} d\tau \\ &= \eta_0 - (1 - k_0) \eta_0 \left[\frac{\cosh \gamma (1 - z_1)}{\cosh \gamma} \right]^{\frac{f(\eta_0)}{f(\eta(0, t))}} \end{aligned}$$

For a successful process we demand that $\eta(z_1, t_f) \leq k_1 \eta_0$, this will be satisfied if we choose α such that :

$$\left[\frac{\cosh \gamma (1 - z_1)}{\cosh \gamma} \right]^{\frac{f(\eta_0)}{f(\eta(0,t))}} \geq \frac{1 - k_1}{1 - k_0} .$$

Since $\frac{1-k_1}{1-k_0} < 1$ we have to find α s.t.

$$\frac{\cosh \gamma (1 - z_1)}{\cosh \gamma} \geq \left[\frac{1 - k_1}{1 - k_0} \right]^{\frac{f(\eta(0,t))}{f(\eta_0)}}$$

α can be made small enough such that the left hand side will be as close to 1 as needed.

The goal of the analysis in the following sections is to find the temperature and pressure that minimize the final time t_f for achieving a successful process.

III Analysis of the Optimization Problem

The final time, t_f is given by (26) and it is a decreasing function of $\beta(P, T)$, given in (12). However β can not be taken arbitrary large without violating the uniformity condition (24). The optimization problem involves therefore maximizing $\beta(P, T)$ with the constraint $\eta(z_1, t_f) \leq k_1 \eta_0$. However the expression for $\eta(z_1, t_f)$, (27), t_f is an integration boundary, which makes it a non-standard optimization problem. In order to overcome this difficulty we make a change of variable, (28), and use the definition for a successful process, (25), to convert the integral boundaries to constants, as was done in the proof for Theorem 2. This change of variable converts the optimization problem to a standard one.

In order to express this constraint explicitly in terms of P and T we can use either by asymptotic expansions or by direct numerical solution of the system (5), (6).

III.a Asymptotic Expansions

In most of the application the parameter α^2 is small, and therefore it makes sense to expand the solutions in power of α^2 . The formal expansion to the order of α^2 is:

$$\begin{aligned} c(z, t) &\sim 1 - \alpha^2 \left(z - \frac{z^2}{2} \right) \frac{E}{f(E)} \\ \eta(z, t) &\sim E + \alpha^2 \left(z - \frac{z^2}{2} \right) \int_E^{\eta_0} \frac{\hat{E}}{f(\hat{E})} d\hat{E} \end{aligned} \tag{29}$$

$$\begin{aligned}
\text{and for } f(\eta) &= \frac{P\eta^3}{3(P\eta + A_D T)} \\
&= E(t) + 3\alpha^2 \left(z - \frac{z^2}{2} \right) \left[\log \left(\frac{\eta_0}{E(t)} \right) + \frac{A_D T}{P} \left(\frac{1}{E} - \frac{1}{\eta_0} \right) \right] \quad (30)
\end{aligned}$$

Where, again,

$$E(t) = \eta_0 - \frac{\beta}{2} t \quad (31)$$

In the following theorem we shall prove that the asymptotic expansion is accurate for order $O(\alpha^4)$

Theorem 3 *For all $0 \leq z \leq 1$, $t \leq t_f$ the difference between the exact solution and the asymptotical approximation is $O(\alpha^4)$.*

Proof By integrating (6) between z to 1, dividing by $f(\eta)$ and integrating between 0 to z one gets

$$c(z, t) = 1 - \int_0^z \frac{1}{f(\eta(\zeta, t))} \int_\zeta^1 \alpha^2 \eta(\xi, t) c(\xi, t) d\xi d\zeta \quad (32)$$

and for η we get, by integrating (5) from 0 to t :

$$\eta(z, t) = \eta_0 - \frac{\beta}{2} \int_0^t c(z, \tau) d\tau = \eta_0 - \int_E^{\eta_0} c(z, e) de . \quad (33)$$

In (32) we use the bounds, $c \leq 1$ that $E \leq \eta \leq \eta_0$ to get

$$c \geq 1 - \alpha^2 \frac{\eta_0}{f(E)} \left(z - \frac{z^2}{2} \right) , \quad (34)$$

and upon substituting (34) into (33) one gets

$$\eta \leq E + \alpha^2 \eta_0 \left(z - \frac{z^2}{2} \right) \int_E^{\eta_0} \frac{1}{f(e)} de . \quad (35)$$

The bounds (34) and (35) can be further refined. Consider, again, the equality (32), but now we use the estimate for η from above (35) and the estimate from below to c (35) to get

$$c \geq 1 - \alpha^2 \frac{E}{f(E)} \left(z - \frac{z^2}{2} \right) - \alpha^4 \frac{\eta_0 \int_E^{\eta_0} \frac{1}{f(e)} de}{f(E)} \left(\frac{z}{3} - \frac{z^3}{6} + \frac{z^4}{24} \right) . \quad (36)$$

In the same way we can get a better estimate estimate from below in c :

$$\eta \leq E + \alpha^2 \left(z - \frac{z^2}{2} \right) \int_E^{\eta_0} \frac{e}{f(e)} de + \alpha^4 \eta_0 \left(\frac{z}{3} - \frac{z^3}{6} + \frac{z^4}{24} \right) \int_E^{\eta_0} \frac{\int_E^{\eta_0} \frac{1}{f(\tilde{e})} de}{f(\tilde{E})} d\tilde{E} . \quad (37)$$

To get an upper estimate on c we use estimate (34) together with $\eta \geq E$ and

$$f(\eta) \geq f\left(E + \alpha^2 \eta_0 \left(z - \frac{z^2}{2}\right) \int_E^{\eta_0} \frac{1}{f(e)} de\right)$$

to get

$$\begin{aligned} c &\leq 1 - \alpha^2 E \int_0^z \frac{(1 - \zeta)}{f(E + \alpha^2 \eta_0 \left(\zeta - \frac{\zeta^2}{2}\right) \int_E^{\eta_0} \frac{1}{f(e)} de)} d\zeta + \\ &\quad \alpha^4 E \eta_0 \int_0^z \frac{1}{f(E + \alpha^2 \eta_0 \left(\zeta - \frac{\zeta^2}{2}\right) \int_E^{\eta_0} \frac{1}{f(e)} de)} \left(\frac{1}{3} - \frac{\zeta^2}{2} + \frac{\zeta^3}{6}\right) d\zeta \\ &\leq 1 - \alpha^2 E \int_0^z \frac{(1 - \zeta)}{f(E + \alpha^2 \eta_0 \left(\zeta - \frac{\zeta^2}{2}\right) \int_E^{\eta_0} \frac{1}{f(e)} de)} d\zeta + \alpha^4 \frac{E \eta_0}{f(E)} \left(\frac{z}{3} - \frac{z^3}{6} + \frac{z^4}{24}\right). \end{aligned} \quad (38)$$

Using the Lipschitz continuity of $1/f$ we get:

$$\begin{aligned} c &\leq 1 - \alpha^2 \frac{E}{f(E)} \left(z - \frac{z^2}{2}\right) + \\ &\quad \alpha^4 E \eta_0 \left[L \left(\frac{z^2}{2} - \frac{z^3}{2} + \frac{z^4}{8}\right) \int_E^{\eta_0} \frac{1}{f(e)} de + \frac{1}{f(E)} \left(\frac{z}{3} - \frac{z^3}{6} + \frac{z^4}{24}\right) \right] \end{aligned} \quad (39)$$

where L is the Lipschitz constant of $1/f$, and by substituting into Eq.(33)

$$\begin{aligned} \eta &\geq E + \alpha^2 \left(z - \frac{z^2}{2}\right) \int_E^{\eta_0} \frac{e}{f(e)} de + \\ &\quad \alpha^4 \eta_0 \int_E^{\eta_0} \tilde{E} \left[L \left(\frac{z^2}{2} - \frac{z^3}{2} + \frac{z^4}{8}\right) \int_{\tilde{E}}^{\eta_0} \frac{1}{f(e)} de + \frac{1}{f(\tilde{E})} \left(\frac{z}{3} - \frac{z^3}{6} + \frac{z^4}{24}\right) \right] d\tilde{E} \end{aligned} \quad (40)$$

Thus the difference between the exact solution and the asymptotical approximation is $O(\alpha^4)$.

In the next subsection the numerical results and the asymptotic expansions are compared, to demonstrate the validity of the expansions in the range of relevant α^2 .

The asymptotic expansion (30) is used to get an explicit form for the uniformity constraint (24) in terms of the temperature T and the pressure P . Substituting (30) into (24) gives:

$$k_0 \eta_0 + 3\alpha^2 (z_1 - z_1^2/2) \left[\log\left(\frac{1}{k_0}\right) + \frac{A_D T}{P \eta_0} \left(\frac{1}{k_0} - 1\right) \right] \leq k_1 \eta_0 \quad (41)$$

Substituting α^2 from (11) yields the following form for the uniformity constraint

$$J(P, T) \leq (k_1 - k_0) \eta_0. \quad (42)$$

where, using the explicit form of $f(\eta)$, see (9), we get

$$J(P, T) = 3A_\alpha \frac{P}{T^{3/2}} e^{-Q/T} (z_1 - z_1^2/2) \left[\log\left(\frac{1}{k_0}\right) + \frac{A_D T}{P \eta_0} \left(\frac{1}{k_0} - 1\right) \right] \quad (43)$$

Thus uniformity is assured if

$$P \leq \frac{B_0}{B_2} T^{3/2} e^{Q/T} - \frac{B_0}{B_2} T, \quad (44)$$

where

$$B_0 = \frac{\eta_0(k_1 - k_0)}{A_\alpha 3(z_1 - z_1^2/2)} \quad (45)$$

$$B_1 = \frac{A_D}{\eta_0} \left(\frac{1}{k_0} - 1\right) \quad (46)$$

$$B_2 = \log\left(\frac{1}{k_0}\right). \quad (47)$$

These results can now be used to approximate the temperature and pressure that minimize the time for a successful process. Recall (see (26)) that the final time t_f is inversely proportional to β given in (12). The final time t_f is therefore minimized if the function

$$F(P, T) = \frac{P}{T} e^{-Q/T} \quad (48)$$

is maximized under the uniformity constraint (25). Inspection of (48) shows that in order to maximize β we have to take the equality sign in (44). Substituting this into (48), it is easily verified that the following function must be maximize:

$$G(T) = \frac{B_0}{B_2} T^{1/2} - \frac{B_1}{B_2} e^{-Q/T} \quad (49)$$

This indicates that the final time t_f to achieve a successful process is minimized by choosing temperature and pressure satisfying

$$T^{3/2} e^{Q/T} = \frac{B_1 Q}{B_0} \quad (50)$$

$$P = \frac{B_1}{B_2} (Q - T) \quad (51)$$

Moreover the minimal final time t_f^{min} is given by

$$t_f^{min} = \frac{2(1 - k_0) \log(1/k_0)}{k_1 - k_0} \frac{A_\alpha Q}{A_\beta X_0} 3(z_1 - z_1^2/2) \frac{1}{T^{1/2}(Q - T)} \quad (52)$$

Where the temperature T is given by (50).

□

The explicit formulas (50)-(52) lead to the following observations:

1. The minimum final time, t_f^{min} , decreases as A_D decreases. (i.e. as the molecular diffusion becomes dominant.)
2. t_f^{min} decreases as k_1 increases. This reflects the fact that increasing k_1 amounts to relaxing the uniformity condition.
3. As z_1 increases toward $z_1 = 1$, the minimum final time t_f^{min} increases.

III.b Computational Results

In the previous subsection the asymptotic expansion of η was used to define a functional $J(P, T)$ such that each pair P, T that satisfies $J(P, T) \leq (k_1 - k_0) \eta_0$ leads to a solution that satisfies the conditions for a successful process, (24), (25). The optimal P and T was then obtained based on the final time. This result is only approximately correct since the asymptotic expansion was used to approximate condition (24). This section uses numerical solutions of (5),(6) to create a 'numerical J functional', (i.e. a functional relation between P and T that ensures a successful process).

Two algorithms were used to solve this problem: one based on a finite difference approximation and one on spectral methods. These are described in the Appendix. The schemes were run with $k_0 = 0.1$, $z_1 = 1$ and $k_1 = 0.15$ or 0.7 . Note that $k_1 = .15$ corresponds to relatively uniform infiltration while $k_1 = .7$ is relatively non-uniform. Although most applications require relatively uniform infiltration (i.e., lower k_1), there are some cases where a non-uniform profile may be desirable. Two reasons for a higher k_1 are that it enables faster infiltration times, and it produces materials with lower density. For example, both of these attributes are desirable during the formation of thin carbon-carbon composites for bipolar plates in proton exchange membrane (PEM) fuel cells [17].

Three values were taken for A_D , $1.54 * 10^{-5}$, $1.93 * 10^{-6}$ and $7.7 * 10^{-7}$ (see Table I). Plots of the numerical and the asymptotic J curves are presented in Figure 1, plots of t_f vs. P are presented in Figure 2.

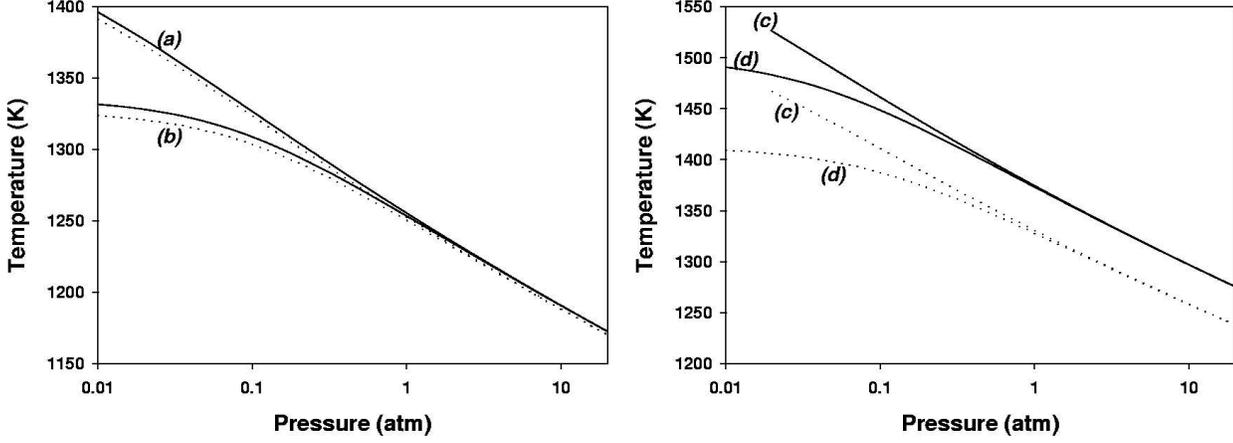


Figure 1: J Curves obtained both numerically (solid lines) and by asymptotic analysis (dotted lines). Conditions on or below these lines will satisfy the uniformity condition (Eq. (3.35)). Conditions above this line do not satisfy the uniformity condition. All cases here correspond to $X_0 = 0.1$, with: (a) $k_1 = 0.15$, $A_D = 1.54 \times 10^{-5}$; (b) $k_1 = 0.15$, $A_D = 7.7 \times 10^{-7}$; (c) $k_1 = 0.7$, $A_D = 1.54 \times 10^{-5}$; (d) $k_1 = 0.7$, $A_D = 7.7 \times 10^{-7}$.

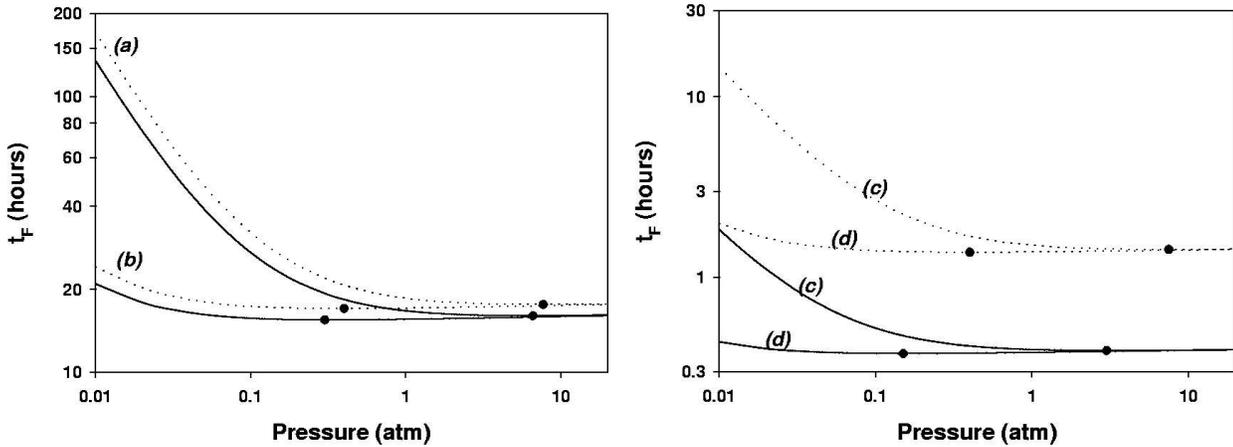


Figure 2: Times which correspond to conditions on the J curves in Fig. 1, with values obtained both numerically (solid lines) and by asymptotic analysis (dotted lines). The filled circles show the minimal time. (a) $k_1 = 0.15$, $A_D = 1.54 \times 10^{-5}$; (b) $k_1 = 0.15$, $A_D = 7.7 \times 10^{-7}$; (c) $k_1 = 0.7$, $A_D = 1.54 \times 10^{-5}$; (d) $k_1 = 0.7$, $A_D = 7.7 \times 10^{-7}$.

Table II: t_f for the optimal P and T .

A_D	k_1	Numerics			Asymptotics		
		P	T	t_f	P	T	t_f
$1.54 \cdot 10^{-5}$	0.15	6.59817	1201.69	57703.5	7.75487	1194.85	63436.4
$1.93 \cdot 10^{-6}$	0.15	0.83	1260.76	56363.4	0.964282	1253.56	61971.3
$7.7 \cdot 10^{-7}$	0.15	0.334636	1288.52	55757.3	0.373109	1282.26	61309.3
$1.54 \cdot 10^{-5}$	0.7	3.11577	1334.74	1416.3	7.70548	1265.71	5139.93
$1.93 \cdot 10^{-6}$	0.7	0.393241	1408.2	1379.66	0.965	1331.69	5014.01
$7.7 \cdot 10^{-7}$	0.7	0.154896	1444.02	1363.1	0.372904	1364.25	4957.04

The process is very sensitive to changes in the temperature T , as can be seen, for example, by comparing the results for $P = .1_{\text{atm}}, T = 1309 \text{ K}$, vs. $P = .1_{\text{atm}}, T = 1449 \text{ K}$. Increasing temperature by 140 degrees decreases the final time by a factor of 55 and produces an infiltration profile which is much less uniform. This occurs because of the strong temperature dependence of the deposition reaction. As the fibers size increases t_f decreases slightly and the minimal time occurs at lower pressures.

When the uniformity requirement dictates $k_1 = .15$ in (24), the condition $J(P, T) = (k_1 - k_0)\eta_0$ yields P and T such that $\alpha^2 \sim .01$. In this case the asymptotic expansions agree well with the numerical results. The predicted temperature to assure uniformity differs by only few degrees from the one obtained numerically, and t_f differs by less than 10%. However when k_1 was increased to .7 the asymptotic expansion is less accurate, because, in this case, $\alpha^2 \sim .1$ is not sufficiently small (See Table II). In all cases, however, the asymptotic results agree qualitatively with the numerical results. The curves obtained numerically were almost parallel to the asymptotic, and the points of minima are almost in the same place. The asymptotic results are conservative, they always overestimated the final time, and gave more restrictive conditions on P and T for uniformity. i.e. P and T obtained by the asymptotic analysis never predict a successful process if it does not exist. However, since P and T obtained by the asymptotic analysis may be much different from the optimal ones (obtained by the numerical analysis), t_f may be much larger than the minimal value (See Table II).

IV Homogeneous Nucleation.

CVI processes can be limited by homogeneous nucleation (i.e., powder formation) in the gas phase. This effect has not been treated in previous CVI models because it generally occurs outside of the solid preform. However, powder formation can impose serious limitations on CVI operating conditions during the formation of carbon and oxide matrices. Thus, this phenomena imposes a constraint on the allowable CVI operating conditions. In practice, the nucleation rate depends on the reactor configuration, as well as its actual value. For the current analysis, we assume that powder formation limits CVI when the nucleation rate exceeds some allowable level, I_{lim} . With this in mind, the following constraint can be presented. (For the derivation on this constraint see [4]).

$$A_{lim} = (X_0 P)^2 / T^{2.5} \exp(-A_I / T^m) \quad (53)$$

where A_{lim} is the maximal nucleation rate specification and the two constants, A_I and m are determined empirically to fit the nucleation model. A good fit to the experimental data of Loll et. al. ,see [13], [14], was obtained with $m = 1.5$, $A_I = 750,000 \text{ K}^m$, and $A_{lim} = 3.3 \cdot 10^{-17} \text{ atm}^2 / \text{K}^{2.5}$. The value of A_{lim} , however, is somewhat arbitrary, since it reflects a threshold for a given reactor. By varying A_{lim} , it is possible to assess different tolerance levels for powder formation. For example, recent carbon CVI experiments at Oak Ridge National Laboratory tolerate higher powder formation levels than those described by Loll et.al. with a threshold value that corresponds to $A_{lim} = 2.0 \cdot 10^{-21} \text{ etm}^2 / \text{K}^{2.5}$. [15].

The effect of adding the powder formation constraint can be seen from Figure 3, where the I -curves are defined by Eq. (53). As seen from the left plot, the new constraint limits the pressures and temperatures to values which are below both the I and the J -curves. For a given pressure, the minimal t_f corresponds to a temperature on either the I or J -curve (whichever is lower). Thus if the minimal t_f found in section 3 (i.e. when P and T are on the J -curves) to the left of the I -curve, then the additional constraint does not change the previous results. If, on the other hand, this point is on the right of the I -curve then, the minimal t_f occurs at the intersection between the I and J -curves. This point can be clearly seen as a cusp in the t_f vs. P in the right plot.

A complete assessment of X_0 effects requires solutions with the full Dusty Gas model, because large values of X_0 violate the assumption of a dilute reactant gas. However, con-

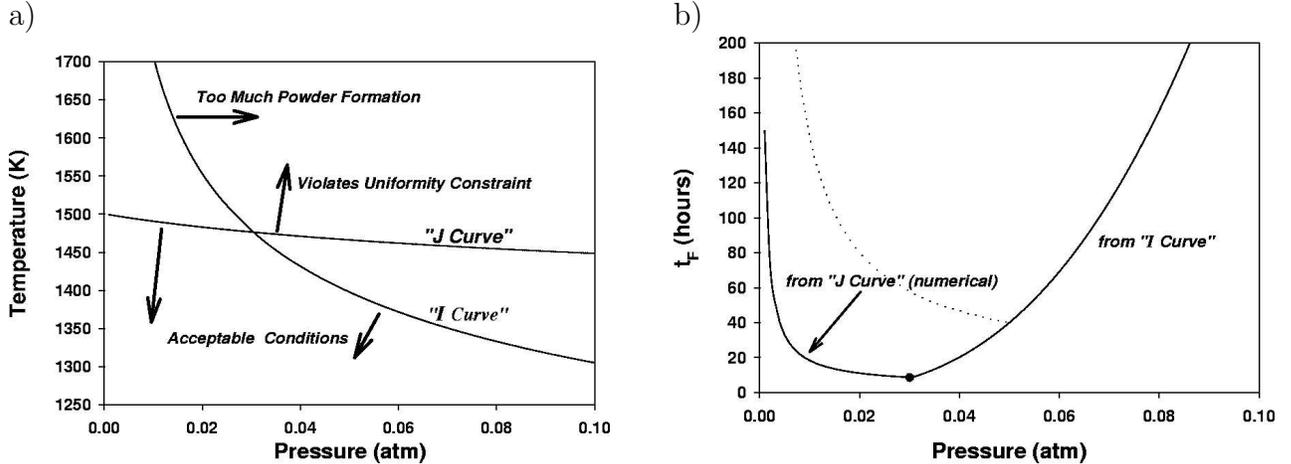


Figure 3: Effect of homogeneous nucleation for $k_1 = 0.7$, $X_0 = 0.01$, $A_D = 1.54 * 10^{-5}$;. (a) The numerically obtained J Curve (uniformity constraint, Eq. (42)) and the I Curve (nucleation limit, Eq. (53) with $A_{lim} = 2.0 * 10^{21}$). (b) Limiting time as a function of pressure. The left part of the curve is determined by the numerically obtained J Curve and the right side is determined by the I Curve, with the minimal time shown by the filled circle. The dotted line corresponds to the approximate J Curve which was determined with asymptotics.

sidering only values up to $X_0 = 0.1$ provides useful insight into optimizing dilute systems. Without the homogeneous nucleation constraint (i.e., as $A_{lim} \rightarrow \infty$), the minimal time is inversely proportional to X_0 , and the optimal pressure and temperature do not vary with X_0 (see section 3). However, homogeneous nucleation limits the operating conditions when A_{lim} is low enough, as illustrated in Fig 3. The effect of this limitation on the optimal conditions and on the minimal time are shown in Fig. 4. These results lead to the following conclusions:

1. As in section 3, the asymptotic results are in good agreement with the numerical results for $k_1 = .15$, where $\alpha^2 \sim .01$, and much less accuracy in the case $k_1 = .7$ where $\alpha^2 \sim .1$. In both cases, however, the asymptotic results agree qualitatively with the numerical results.
2. Notwithstanding the dilute reactant gas restriction, t_f are monotonically decreasing functions of X_0 , thus it is advisable to work in the 'highest' X_0 possible. However since the optimal P is also a monotonically decreasing functions of X_0 , this value of X_0 is limited by the lowest operational pressure. For example for working pressure of about 0.01_{atm} , the maximum allowable X_0 is only 0.05 , for $200_{\mu m}$ diameter fibers

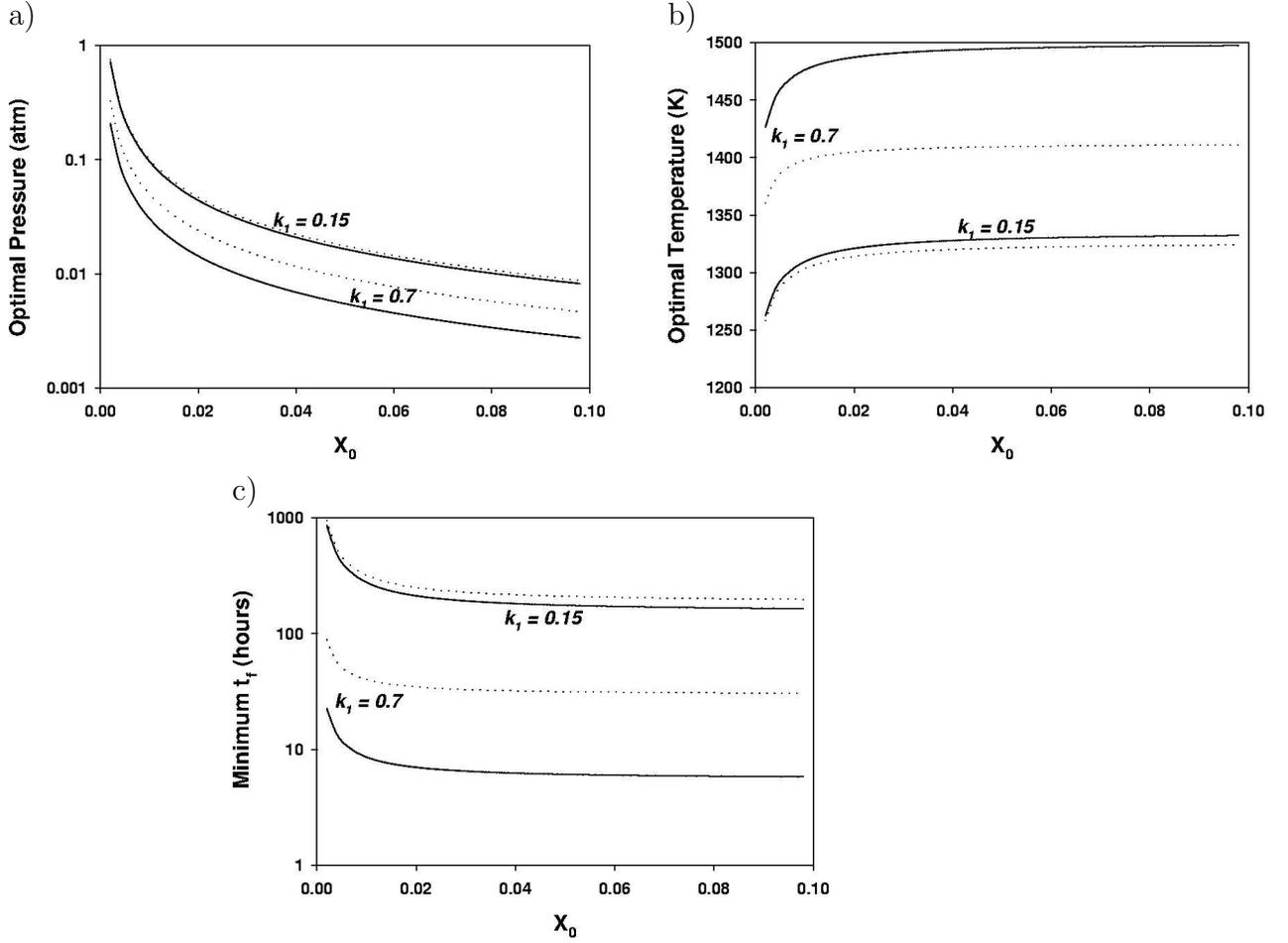


Figure 4: Effect of X_0 with $A_D = 7.7 \cdot 10^{-7}$: (a) optimal pressures; (b) optimal temperatures; (c) minimum infiltration times.

$$(A_D = 7.7 \cdot 10^{-7}).$$

- For a given X_0 , as the fiber diameter increases P and t_f decrease and T increases. But unlike section 3, the differences here are significant. This occurs because the homogeneous nucleation condition forces us to work in a region where the dependence on A_D is much stronger.
- The homogeneous nucleation constraint causes the optimal temperature and pressure to vary with X_0 .

Note that the minimum infiltration time is dramatically increased when there is a significant limitation imposed by homogeneous nucleation. In general, the process must be operated at lower pressures to avoid powder formation. Some increase in the corresponding

optimal temperature accompanies this decrease in pressure.

V Conclusions

Minimizing infiltration times for isothermal, isobaric CVI is important because processing times are typically very long. The work presented here provides a detailed assessment of the pressure and temperature which will minimize the total required time, based on a simplified model for a single, dilute reactant species. This formulation makes it possible to understand the basic physics of the problem in terms of a relatively small number of lumped parameters. The basic objective of this optimization problem is to obtain a density profile with a prescribed amount of uniformity, in the shortest possible time (section 3). The asymptotic results are particularly useful, because they make it possible to determine optimal conditions without doing numerical calculations (under conditions where α^2 is small enough). Based on comparisons with the numerical results, the asymptotic forms are also qualitatively accurate when α^2 is larger. Thus, the asymptotic results provide a clear understanding of how the optimal conditions are related to the key parameters for the problem. The effects of homogeneous nucleation were also analyzed, as an additional constraint on the basic optimization problem. This issue has not been considered in previous work on CVI modeling, however, it can limit operating conditions in systems where powder formation is significant (e.g., the formation of carbon matrix composites). The results obtained here provide a quantitative assessment of the conditions where homogeneous nucleation imposes limitations on infiltration conditions. When these limitations occur, powder formation also increases the minimum infiltration time.

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